



THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of: **Koji NOZAKI et al.**

Art Unit: **1752**

Application Number: **10/623,679**

Examiner: **Amanda C. Walke**

Filed: **July 22, 2003**

Confirmation Number: **5083**

For: **RESIST PATTERN THICKENING MATERIAL, RESIST PATTERN AND
PROCESS FOR FORMING THE SAME, AND SEMICONDUCTOR DEVICE
AND PROCESS FOR MANUFACTURING THE SAME**

Attorney Docket Number: **030891**

Customer Number: **38834**

PETITION FOR EXTENSION OF TIME

Commissioner for Patents
P. O. Box 1450
Alexandria, VA 22313-1450

February 22, 2008

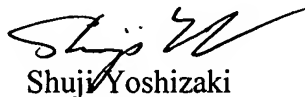
Sir:

Applicants petition the Commissioner for Patents to extend the time for response to the Office Action dated October 2, 2007 for two months from January 2, 2008 to March 2, 2008.

Attached please find a check in the amount of \$460.00 for the cost of the extension of time. If any additional fees are due in connection with this paper, please charge Deposit Account No. 50-2866.

Respectfully submitted,

WESTERMAN, HATTORI, DANIELS & ADRIAN, LLP


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Attachment: Check of \$460.00